



30827

1 Receipt

Docket No.: 8733.154.00-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Jin Jang, et al.

Application No.: 09/350,313

Group Art Unit: N/A

Filed: July 9, 1999

Examiner: Not Yet Assigned

For: METHOD OF CRYSTALLIZING
AMORPHOUS SILICON LAYER AND
CRYSTALLIZING APPARATUS THEREOF

REQUEST FOR CORRECTED FILING RECEIPT

Office of Initial Patent Examination Customer Service Center
Commissioner for Patents
Washington, DC 20231

Dear Sir:

Applicant hereby requests that a corrected Filing Receipt be issued in the above-identified patent application. The official Filing Receipt received by Applicant, a copy of which is attached hereto, has an error in

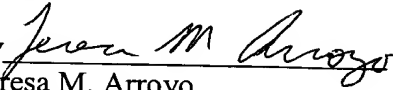
Applicant(s): Change applicant name from Wood-Sung Shon to Woo-Sung Shon

Applicant additionally requests that all pertinent U.S. Patent and Trademark Office records relating to the subject application be changed to reflect this correction.

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Dated: April 30, 2002

Respectfully submitted,

By 
Teresa M. Arroyo

Registration No.: 50,015

Song K. Jung

Registration No.: 35,210

LONG ALDRIDGE & NORMAN LLP

701 Pennsylvania Avenue N.W.

Suite 600

Washington, DC 20004

(202) 624-1200

Attorneys for Applicant



UNITED STATES PATENT AND TRADEMARK OFFICE

COMMISSIONER FOR PATENTS
UNITED STATES PATENT AND TRADEMARK OFFICE
WASHINGTON, D.C. 20231
www.uspto.gov

APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/350,313	07/09/1999	1765	1856	008733- 20019 8733.15400	7	25	6

30827
LONG ALDRIDGE & NORMAN, LLP
701 PENNSYLVANIA AVENUE N.W.
SUITE 600
WASHINGTON, DC 20004

CONFIRMATION NO. 7883
CORRECTED FILING RECEIPT



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Date Mailed: 04/22/2002

Receipt is acknowledged of a CPA in this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

JIN JANG, SEOUL, KOREA, REPUBLIC OF;
SOO-YOUNG YOON, DAEJEON, KOREA, REPUBLIC OF;
JAE-YOUNG OH, JEJU-SHI, KOREA, REPUBLIC OF;
WOOD-SUNG SHON, SEOUL, KOREA, REPUBLIC OF;
SEONG-JIN PARK, SEOUL, KOREA, REPUBLIC OF;

Domestic Priority data as claimed by applicant

Foreign Applications

REPUBLIC OF KOREA 98-27716 07/10/1998
REPUBLIC OF KOREA 98-44230 10/21/1998

If Required, Foreign Filing License Granted 08/04/1999

CPA filed on: 04/16/2002

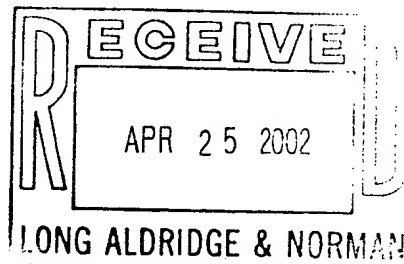
Projected Publication Date: 08/01/2002

Non-Publication Request: No

Early Publication Request: No

Title

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METHOD OF CRYSTALLIZING AMORPHOUS SILICON LAYER AND CRYSTALLIZING
APPARATUS THEREOF

Preliminary Class

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Title 37, Code of Federal Regulations, 5.11 & 5.15

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